

10/564453

Customer No. 20,995

Docket No.: SHIGA7.041APC

IAP20 Rec'd PCT/US 12 JAN 2006

INFORMATION DISCLOSURE STATEMENT

Applicant : Masudo et al.
App. No : Unknown
Filed : Herewith
For : POSITIVE PHOTORESIST
COMPOSITION AND METHOD OF
FORMING RESIST PATTERN
Examiner : Unknown
Art Unit : Unknown

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 13 references to be considered by the Examiner. Also enclosed are 9 foreign patent references and/or non-patent literature as listed on the Information Disclosure Statement. Please note that US 2003/0059706 A1 corresponds to JP 2002-258479; US 4,847,178 corresponds to JP 62-262043; and US 6,319,853 B1 corresponds to JP 11-204399.

This Information Disclosure Statement is being filed within three months of the filing date, and no fee is required.

The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment, to Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 12 Jan. 2006

By: Daniel E. Altman

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Application No.	Unknown 10/564453
		Filing Date	Herewith
		First Named Inventor	Masuda, Yasuo
		Art Unit	Unknown
(Multiple sheets used when necessary)		Examiner	Unknown
SHEET 1 OF 1		Attorney Docket No.	SHIGA7.041APC

U.S. PATENT DOCUMENTS					
Examiner Initials	Cite No.	Document Number <i>Number - Kind Code (if known)</i> Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
/	1	US 2003/0059706 A1	03-27-2003	Misumi et al.	
/	2	6,319,853 B1	11-20-2001	Ishibashi et al.	
/	3	4,847,178	07-11-1989	Komano	
/	4	6,187,500 B1	02-13-2001	Miyagi et al.	

FOREIGN PATENT DOCUMENTS						
Examiner Initials	Cite No.	Foreign Patent Document <i>Country Code-Number-Kind Code</i> Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T ¹
/	5	EP 0 650 091 A1	04-26-1995	Sumitomo Chemical Co.		
/	6	EP 0 677 789 A1	10-18-1995	Fuji Photo Film Co. Ltd		
/	7	JP 11-204399	07-30-1999			
/	8	JP 11-223937	08-17-1999	Fuji Film Olin KK		Abstract
/	9	JP 05-107755	04-30-1993	Fuji Photo Film Co. Ltd.		Abstract
/	10	JP 62-262043	11-14-1987			
/	11	JP 2002-258479	09-11-2002			
/	12	JP 47-43315	11-01-1972			Abstract

NON PATENT LITERATURE DOCUMENTS						
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.				T ¹
/	13	Organic Compounds Structural Index, pp. 362-401, 20 December 1977; Maruzen (Ltd.)				
/						
/						

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Examiner Signature	Date Considered
*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	

T¹ - Place a check mark in this area when an English language Translation is attached.